Electronic Acknowledgement Receipt

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Application Number:	10524525
International Application Number:	
Confirmation Number:	1134
Title of Invention:	Method for selectively removing material from the surface of a substrate, masking material for a wafer, and wafer with masking material
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Document Number	Document Description	File Name	File Size(Bytes)/ Message Digest	Multi Part /.zip	Pages (if appl.)
1	Information Disclosure Statement (IDS) Filed (SB/08)	BEET-09_US_IDS_Form__SB_08a_3rdSupp.pdf	617000 daaa565e1ce2525021f9511d8aaf70d81c171398	no	4

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| 2 | Foreign Reference | JP7115209.PDF | 1602170 | no | 12 |
| | | | 7ff8cc1c2b3a361887dcfc8f993557d13728c582 | | |

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| 3 | Foreign Reference | JP8148468.PDF | 700448 | no | 7 |
| | | | 8e1b34288ca784399d0917177f86906eea08cb32 | | |

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| 4 | Foreign Reference | JP10261713.PDF | 1244971 | no | 10 |
| | | | 5e41d27184371bf151db2b166ac3218368f0ff59 | | |

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| 5 | Foreign Reference | JP2000124564.PDF | 1453443 | no | 9 |
| | | | 669ce32081b7635824c13d097cb76663892d88a0 | | |

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| 6 | Foreign Reference | JP200185388.PDF | 1139986 | no | 8 |
| | | | 4c2dd722c80de89538d6ee99b04b4576bb731b97 | | |

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| 7 | Foreign Reference | JP2001345311.PDF | 2200078 | no | 15 |
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